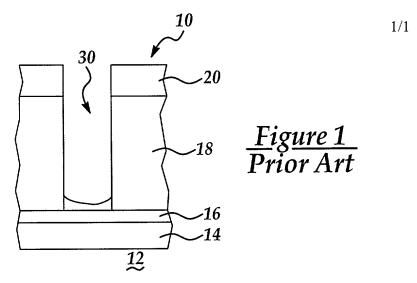
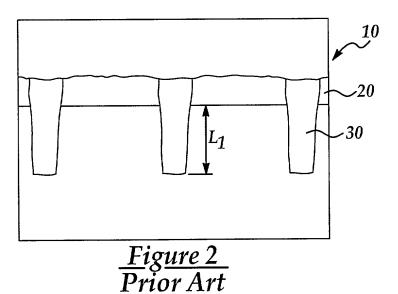
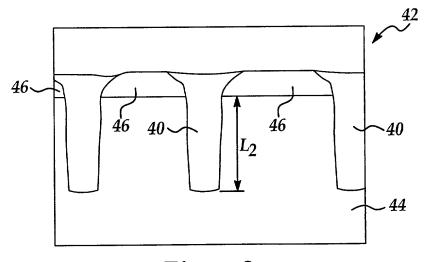
For: METHOD FOR FORMING VIA AND CONTACT HOLES WITH DEEP UV PHOTORESIST

Attorney Docket No.: 67,200-549







<u>Figure 3</u>

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